



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :
Nicholas A. WARD et al. :
Serial No. 09/927,444 : Group Art Unit: 2125
Filed: August 13, 2001 : Examiner: Sean P. Shechtman
For: Dynamic Control Of Wafer Processing Paths In
Semiconductor Manufacturing Processes

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Technology Center 2100

Honorable Commissioner for Patents
Alexandria, VA 22313-1450

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated January 20, 2004 for three months, from April 20, 2004 to July 20, 2004.

Please charge the \$950.00 fee to cover the cost of the extension to Deposit Account No. 08-0219. Any deficiency or overpayment should be charged or credited to Deposit Account No. 08-0219.

Respectfully submitted,

Wilmer Cutler Pickering Hale and Dorr LLP


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Date: July 13, 2004

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